

Alva's Institute of Engineering & Technology

Shobhavana Campus, Mijar, Moodbidri, D.K - 574225 Phone: 08258-262725, Fax: 08258-262726

Report

FACULTY DEVELOPMENT PROGRAM

ON

"Intellectual Property Rights-Patent Act"



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Name of the Program: Intellectual Property Rights- Patent Act

Details of the Resource Person: The resource person for FDP was Mr. Ajith Kumar. Mr. Ajith Kumar is an Advocate, and working as Guest Lecturer in Alva's Institute of Engineering and Technology, Moodbidri. He has completed his L.L.B from Mangalore University in 2009 and L.L.M. at S.D.M Law College, Mangalore in the year 2012. He is expertise in delivering informative talks on IPR and Patent filings

Brief Report of the Program: In any research patent is very important because it can help to safeguard your invention. It can protect any product, design or process that meets certain specifications according to its originality, practicality, suitability, and utility. To give the awareness of patents AIET conducted one day FDP on Intellectual Property Rights- Patent Act on 14/07/2018 in Room No-103. The FDP was conducted for all the faculties of AIET.

During the FDP, Mr. Ajith Kumar explained about the importance of Intellectual Property Rights and its importance to research, along with its objective and scope of the research. IPR is related to research publications. He explained how to apply for patent and different types of patents. Knowing about the patent act is the important need for any researcher before filing any patents.



Mr. Ajith Kumar explaining about IPR during the the session

Total of 26 faculties have attended the FDP from different departments of AIET. After attending this valuable session, the audience could able to know about the importance of Intellectual Property Rights in research. Also, the audience got a brief idea about different types of patents and how to apply for patent following the patent act.

Co-Rdinator